



PATENT
8565D-7213 (81839.0077)
Express Mail Label No. EL 713 623 895 US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Teruaki FUKAMI

Serial No: 09/218,997

Filed: December 22, 1998

For: SILICON WAFER STORAGE
WATER AND SILICON WAFER
STORAGE METHOD

Art Unit: 1744

Examiner: I. Soubra

14/B
AS
11/27/01

PRELIMINARY AMENDMENT

Box CPA
Commissioner for Patents
Washington, D.C. 20231

RECEIVED

NOV 28 2001

TC 1700

Dear Sir:

Prior to examination of the above-identified Continued Prosecution Application (CPA), please amend the application as follows:

IN THE CLAIMS:

Rewrite claim 1 as follows:

Sub D1
B1
1. (Twice Amended) A storage water used for storage of a silicon wafer in water, wherein the storage water contains Cu at a concentration of 0.01 ppb or less and a surfactant.

Cancel claim 2, without prejudice.